

2D detectors and application of XPAD pixel detector in material sciences : powder and multilayers.

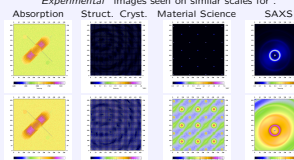


Feb. 20th, 2006 **Campinas synchrotron**

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Synchrotron experiments images.



LINEAR or LOG scaled views show that requirements are very different between experiments.

Absorption images.

Evidence weakly contrasted details using the weakest radiation dose.

In Fourier transform, significant magnitudes near origin :

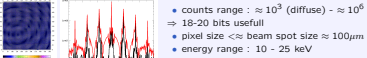


- small details \Rightarrow expected resolution 50 μ m
- $\Delta \approx 0.01 \Rightarrow \sigma \Rightarrow$ counts $\gg 10^4 \Rightarrow 14-16$ bits
- operate at high energy (80 keV) : high Z sensor needed (GaAs)

MEDIPIX (CERN) Llopart, IEEE-TNS 2002, MPEC (Bonn) Lindner, NIM 2000

Structure collection (PX).

Structure collection : **integrate quickly** the maximum number of peaks.

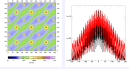


- counts rate : $\approx 10^3$ (diffuse) $\sim 10^6$
 \Rightarrow 18-20 bits useful
- pixel size $<$ beam spot size $\approx 100\mu$ m
- energy range : 10 - 25 keV
- integration (5 pixels) over background \Rightarrow at least 25 pixels/peak
- very big surface : a few 10^6 pixels required
- detector motion are restricted : $2\theta_{max} < 10^\circ$

PILATUS (PSI) Brömmelman, JSR 2002, PSI 2005

Material Science or Solid state physics

Exploration of reciprocal space, profile shape, diffuse scattering...
The Fourier transform of the image is widely spread.



- 5 keV - 25 keV
- 1 to 10^9 photons/s (BM2) \Rightarrow 32 bits useful
- resolution optimized during experiment by adjusting detector position
- pixel size $\approx 200\mu$ m \gg beam spot size
- detector has to be fixed on goniometer arm \Rightarrow mass, connection

XPAD project (BM2 ESRF, IN2P3, CNRS-CEA)
Berar, JSR 2001, Boudet NIM-B 2004, Basile IEEE-TNS 2005

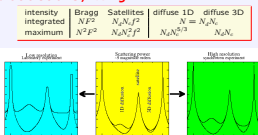
Small Angle Scattering

Measure simultaneously data at low and high Q.



- 10 keV - 25 keV
- 10^{-2} to 10^5 photons/s \Rightarrow 32 bits useful
- small pixels needed around the beam stop
- Pixel size $\approx 200\mu$ m \gg beam spot size
- Real time acquisition with a frame time ≈ 1 ms and dead time < 1 ms
- The requirements are very similar to the previous ones and are a target in the XPAD project.

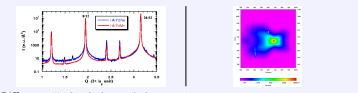
New detectors, why ?



- Experimental resolution increases the required dynamic.
- $I_{Bragg} > 10^9$ (BM2 ESRF) \Rightarrow saturation or attenuation.
- $F \propto \sqrt{I} \Rightarrow$ dynamique(1).

On D2AM-CRG/ESRF beamline (BM2).

Very demanding experiments use slits and photomultipliers to reach the required quality.



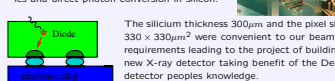
In structural works, CCD cameras with indirect photon detection are commonly used.

Data from M. de Boissieu, see PhD. Mag. Lett. (2001) 61, 213-263 and (2003) 63, 1-29

D2AM-CRG/ESRF detector requirement

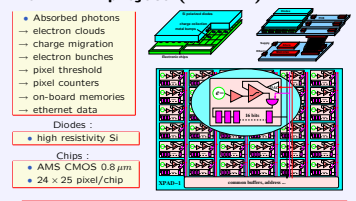
dynamic range $> 10^9$ count/pixel \Rightarrow 32 bits architecture
saturation rate $> 10^7$ v/s/pixel \Rightarrow noise < 0.1 v/s/pixel
energy range 5 - 25 keV from beamline
pixel size 250 x 400 μ m² mean spot size in 1995
exposure time 1ms - 1000s kinetics potentiality

High energy physics experiments lead to built detector like Delphi at CERN which uses the potentialities offered by microelectronics and direct photon conversion in silicon.



The silicon thickness 300 μ m and the pixel sizes 330 x 330 μ m² were convenient to our beamline requirements leading to the project of building a new X-ray detector taking benefit of the Delphi detector peoples knowledge.

The XPAD project (XPAD1).

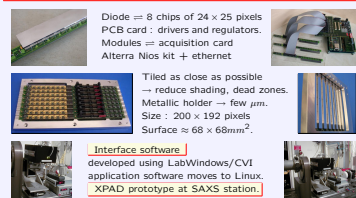


Diodes : high resistivity Si
Chips : AMS CMOS 0.8 μ m, 24 x 25 pixel / chip

Boudet et al., NIM A510 (2003) 43-44, Berar et al., J. Appl. Cryst. 35 (2002) 471-476

XPAD2 detector : 8 modules x 8chips

New diodes of 500 μ m Si thin \rightarrow efficiency 78 % @15keV, 21% @25keV



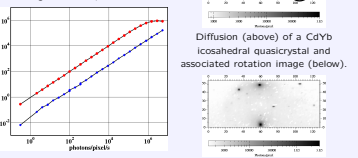
Diode = 8 chips of 24 x 25 pixels
PCB card : drivers and regulators.
Modules = acquisition card Altera Nios kit + ethernet

Tiled as close as possible \rightarrow reduce shading, dead zones.
Metallic holder \rightarrow few μ m.
Size : 200 x 192 pixels
Surface $\approx 68 \times 68$ cm².

Interface software developed using LabWindows/CVI application software moves to Linux. XPAD prototype at SAXS station.

Dynamical range (XPAD1)

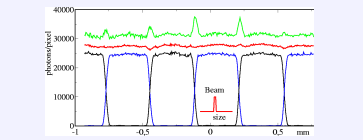
The curves show the counts in two adjacent pixels as a function of the incoming flux on the more exposed pixel using XPAD chips.



Diffusion (above) of a CdYb icosahedral quasicrystal and associated rotation image (below).

Spatial resolution

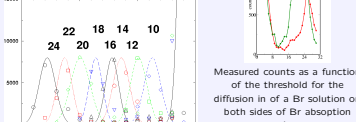
As the diode is common to pixels belonging to the same chip, some charge sharing may occur between adjacent pixels. Measurements show that the charge sharing occurs on a 60 μ m. This effect is a physical limitation of pixel size associated with absorption process. There is no significative influence of the bias field in the diode.



A flat field can be obtained when energies edge is perfectly adjusted in each pixel (red). In case of too low edges, this share sharing create some overcounting at pixel borders (green).

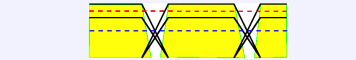
Energy resolution

The conversion of incoming photons in silicon leads to a charge proportional to the incoming energy. The XPAD chip energy resolution is near 1keV.



Measured counts as a function of the diffusion in of a Br solution on both sides of Br absorption edge.

Energy resolution versus flat pixel detectors



- Removing fluorescence**
Due to charge sharing on pixel borders rejecting $E - 1$ keV create dead zones on this border with size $d \approx 60\mu$ m : the flatfield will look like the yellow surface.
 \Rightarrow restricted to pixel size $D > d$: dead area $\approx 2d/D$
- Removing harmonics** needs a energy window with upper edge
More complicated : 2E photons in the border zone are counted as E photons
Ratio reduced only by $\approx d/D \Rightarrow$ optics are more efficient!

Kinetics : low resolution powders

Very quick reactions, for solid state scientists, do not require such a high resolution but more flux and better detectors.

- Laser melting and solidification of oxides.
- Magnetic induction melting and solidification of metals.
- Self-Propagating High-Temperature Synthesis of alloys.

These systems are badly triggered and memory buffers must ensure to record the short phenomenon, most transformations occur in ≈ 100 ms but the whole process takes a few seconds (≈ 10 s).

- To study such phases diagram, various setups can be considered.
- Moving films (IF) are often too slow.
- Gas detectors with dedicated acquisition electronics (256 frames of 10 ms, no read out time) : limited detector coating rate (μ g/min, Thesis, Nancy 1998)
- X-Ray Intensifier and Frelon CCD camera (25ms frames but readout time 110ms/frame) (C. Curfs, Thesis 2002, ESI 2107 μ m²)
- Pixel or strip detectors : the way to success if they reach the angular aperture needed, limited by windows of cell and the prototype number of pixels.

Kinetics potentiality of XPAD2

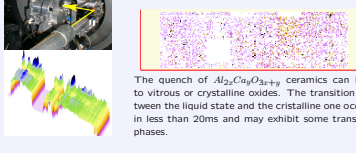
- Whole electronic designed to allow kinetics studies (ms range)
- chips register 16bits + overflow
- on-board memories 32 bits
- exposure time : 1ms - 8300s
- dead time for reading :
- whole image 2ms
- overflow 16 μ s each 10ms
- on-board storage :
- 423 images < 10ms
- 233 images ≈ 10 ms



Images of 10 ms each taken off a 2s movies showing diffraction while the sample crosses the beam at D2AM SAXS camera.

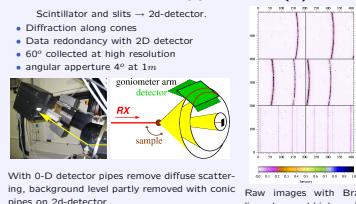
Kinetics of quench studied by diffraction

Data collection is limited by the cell aperture, which has been designed for linear detector, a few frames of 20ms around crystallisation shown at 10 frames/s during CaAl₂O₇ quench.



The quench of Al₂O₃-CaO-O_{2-x} ceramics can lead to vitreous or crystalline oxides. The transition between the liquid state and the crystalline one occurs in less than 20ms and may exhibit some transient phases.

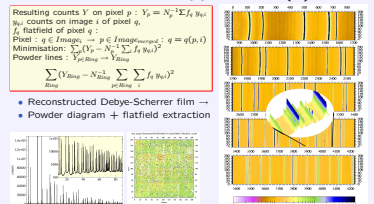
Powder diffraction application (1)



With 0-D detector pipes remove diffuse scattering, background level partly removed with conic pipes on 2d-detector.

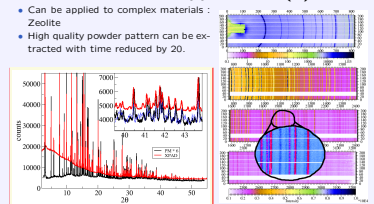
Raw images with Bragg lines, low and high angles.

Powder diffraction application (2)



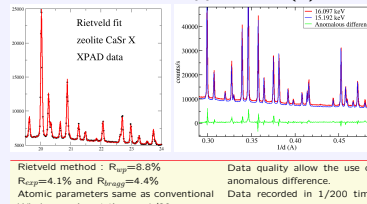
Reconstructed Debye-Scherrer film \rightarrow Powder diagram + flatfield extraction

Powder diffraction application (3)



Can be applied to complex materials : Zeolite

Powder diffraction application (4)

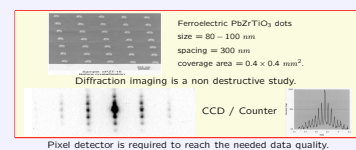


Rietveld fit zeolite CaSx data
Rietveld method : $R_{wp} = 5.8\%$
 $R_{exp} = 4.1\%$ and $R_{p} = 4.4\%$
Anomalous parameters same as conventional
Data quality allow the use of anomalous difference.
Data recorded in 1/200 time will lead to similar results.
Whole experiment time $\rightarrow 1/20$.

Multilayers

Challenging applications on material science beamlines consist in :

- anomalous mapping of layered materials
- local structure of self organized layers (Qdots...)



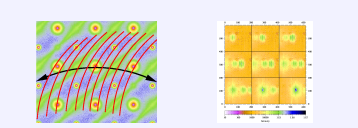
Ferroelectric PbZrTiO₃ dots
size = 80 - 100 nm
spacing = 300 nm
coverage area = 0.4 x 0.4 mm².

Diffraction imaging is a non destructive study.

Pixel detector is required to reach the needed data quality.

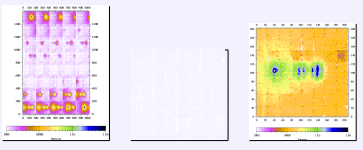
Multilayers measurements

Epitaxially grown multilayer are now common sample to characterize : they need mapping of the reciprocal space in time consuming. At the time such maps are recorded with slits and fixed (h, k, l) point of the reciprocal lattice, attenuator are often required near the substrate. 2-D detection allows an important improvement in these acquisition but it need to be able to manage high dynamics and to transform your reciprocal slices into reciprocal maps.



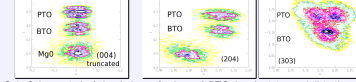
Multilayers slice / integration

A PbT superlattice / MgO has been integrated along the (001) direction. Images of 200s have been recorded from 5.95 to 4.05 with a 1 step of 0.05. This was preferred to direct integration of this space as it allows to measure more accurately the shape of the lower peaks.



Multilayers ; Ferroelectric superlattice

27 (17 PbTiO₃/17 BaTiO₃) superlattice / MgO : large lattice mismatch \rightarrow in-plane polarization \rightarrow tetragonal distortion. Physical behaviour of such compounds is primarily dependent on their epitaxial crystalline quality, their composition and their structural perfection.



Out of plane : strain / chemical In plane : 2 PTO domains tetragonal distortion
The reciprocal maps are recorded scanning the XPAD detector and rebuilt from the collected reciprocal slices. Compared to standard data collection the time can be reduced by 100. Intensity on substrate peak can reach 10^{10} p/s !

F. Lemaire, E. Doornyck and coll. IUCR (2005) Florence, Italy

A new detector using last XPAD2 chips.

- The detector build in winter 2004 has some defects and few chips were damaged by some experiments.
- A new one was assembled using spare chips and best remaining modules. It was mainly used for the small animal tomography project.



Small animal tomography : few frames (18/72) from a mouse rotated in laboratory X-ray beam and the 3D reconstruction of the bones by tomography. Note that all chips have been repaired and no more defects can be evidenced.

project in collaboration with R. Khoun, C. Moril, F. Peyrin, D. Sappay-Marinier, S. Valton

CCDs compared to hybrid pixels

	direct CCD	FO CCD	XPAD2
X ray detector coupling	silicium 20 μ m	fluo screen 50 μ m optical (4+times)	silicium 330 μ m electric
1 μ @ 10keV	3000e ⁻	1 - 5e ⁻	3000e ⁻
saturation	10 ⁷ e ⁻	10 ⁹ e ⁻	10 ⁷ e ⁻
Energy resol.	10%	≈ 1	10%
Read	90% dead time	≈ 1	≈ 0.01
Flux Max	10 ⁷ v/s/detector	X / optical	10 ⁹ v/s/pixel
Shutter	X	14-16bit	integrated
Dynamic range	X	X	integrated
Sensitivity	0.001v/s/pixel	0.5v/s/pixel	0.01v/s/pixel
Measurement	counting	Integration	counting
Limitations	counting	dark removing	counting
		blooming effect	
Opt. usage	Speckle	Structure	Mat. Sciences

from XPAD2 to XPAD3

- Obsolescence of the AMS-CMOS 0.8 μ m technology used for XPAD2
 - A new XPAD3 using 0.25 μ m technology with 25 μ m bumps
- | | XPAD2 | XPAD3 | comments |
|-----------------|-------------------------------------|--------------------------------------|-----------------------------|
| polarization | both | e ⁺ | 2 chips : Si, CdTe |
| pixel size | 330 μ m | 130 μ m | |
| chip size | 8 x 10 mm ² | 10 x 15 mm ² | \rightarrow reduce tiling |
| counting rate | 2.10 ⁶ ph/s | 2.10 ⁶ ph/s | \equiv count/surface |
| energy range | (5) 15 - 25keV | 7 - 25keV | new analog chain |
| pixels/chip | 24 x 25 = 600 | 80 x 120 ≈ 1 10 ⁴ | |
| pixels/module | 8 x 600 ≈ 5 10 ³ | ≈ 1 10 ⁵ | |
| pixels/detector | ≈ 5 10 ³ | ≈ 5 10 ⁵ | |
| geometries | 8 x 8 or 2 x 5 | 7 x 8 and ? | |
- Chip design has been carried out
 - Prototype is expected for mid 2006.